Guest Editorial Introduction to the Special Issue on the 10th Asia-Pacific Symposium on Plasma Technology (APSPT 2017)

THE Asia-Pacific International Symposium on the Basics and Applications of Plasma Technology (APSPT) has been held in Taiwan or Japan every two–four years since 1997. It is an important annual event in the Asia–Pacific area and has been a great platform for scientists all around the world sharing novel and state-of-the-art research findings and exchanging innovative ideas in the field of plasma science and technology. The 10th APSPT was held on December 15–17, 2017 at Chung Yuan Christian University, Taoyuan, Taiwan. There has been a very strong program including 207 papers contributed by participants from eight countries. This Special Issue focuses on the following topics, which were also the focus topics in the 10th APSPT:

1) Plasmas in Biomedical Applications
2) Plasmas in Semiconductor Materials Processing
3) Plasmas in Nano-Materials Processing
4) Plasma Coating and Surface Modifications
5) Plasmas in Agricultural Applications
6) Plasmas in Energy & Environmental Applications
7) Plasmas in Aerospace/Space Applications
8) Fundamentals and Applications of Atmospheric-Pressure and Multiphase Plasmas
9) Fundamentals and Applications of Low Pressure Plasmas
10) Plasma Diagnostics and Modeling
11) Advanced and Novel Plasma Technologies and Sources
12) Thermal Plasmas
13) Space Plasmas

As Guest Editors, we would like to thank the authors who submitted papers and the referees for their timely review. We would also like to acknowledge the Editor-in-Chief, Dr. S. Gitomer, and the Senior Editor, Prof. P. Chu, for their guidance and help throughout the review process. We hope this Special Issue will help exchanging our knowledge in plasma science and cultivate potential collaboration in the community. We look forward to seeing all participants again in the 11th APSPT at Kanazawa University, Kanazawa, Japan, in December 12–14, 2019.

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Kungen Teii received the B.E. and Dr. Eng. degrees from The University of Tokyo, Tokyo, Japan, in 1992 and 1998, respectively.

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Dr. Teii was a Guest Editor of the IEEE TRANSACTIONS ON PLASMA SCIENCE from 2013 to 2014 and from 2015 to 2016.